

	Hits	Search Text	DBs
3	0	(phase near9 shift\$4 near9 mask) and (pluralit\$4 same (transparent or transmiss\$6)) and ((pluralit\$8 or multi\$4) same phase\$5shift\$4) and (feature same transparent) and (phase\$5shift\$\$ same "180") and (phaseshift same ("0" or zero)) and ((irradiat\$4 or illuminat\$4 or expos\$4) same (photoresist or resist or photosensitive)) and (chromeless same (phase near9 shift\$4 near9 mask))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
4	0	(phase near9 shift\$4 near9 mask) and ((pluralit\$8 or multi\$4) same phase\$5shift\$4) and (feature same transparent) and (phase\$5shift\$\$ same "180") and (phaseshift same ("0" or zero)) and ((irradiat\$4 or illuminat\$4 or expos\$4) same (photoresist or resist or photosensitive)) and (chromeless same (phase near9 shift\$4 near9 mask))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
5	0	(phase near9 shift\$4 near9 mask) and (feature same transparent) and (phase\$5shift\$\$ same "180") and (phaseshift same ("0" or zero)) and ((irradiat\$4 or illuminat\$4 or expos\$4) same (photoresist or resist or photosensitive)) and (chromeless same (phase near9 shift\$4 near9 mask))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
6	15	(phase near9 shift\$4 near9 mask) and (pluralit\$4 same (transparent or transmiss\$6)) and ((pluralit\$8 or multi\$4) same phase\$5shift\$4) and (feature same transparent) and ((irradiat\$4 or illuminat\$4 or expos\$4) same (photoresist or resist or photosensitive)) and (chromeless same (phase near9 shift\$4 near9 mask))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
7	1	430/5.ccls. and ((phase near9 shift\$4 near9 mask) same chrome\$2less) and (pluralit\$4 same (transparent or transmiss\$6) same (feature or pattern)) and ((pluralit\$8 or multi\$4) same phase\$5shift\$4) and ((irradiat\$4 or illuminat\$4 or expos\$4) same (photoresist or resist or photosensitive) same ((contact near9 hole) or trench or (metal\$3 near9 line) or (memory near9 cell) or (logic near9 cell)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
8	1	((phase near9 shift\$4 near9 mask) same chrome\$2less) and (pluralit\$4 same (transparent or transmiss\$6) same (feature or pattern)) and ((pluralit\$8 or multi\$4) same phase\$5shift\$4) and ((irradiat\$4 or illuminat\$4 or expos\$4) same (photoresist or resist or photosensitive) same ((contact near9 hole) or trench or (metal\$3 near9 line) or (memory near9 cell) or (logic near9 cell)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
9	18	((phase near9 shift\$4 near9 mask) same chrome\$2less) and (pluralit\$4 same (transparent or transmiss\$6) same (feature or pattern)) and ((pluralit\$8 or multi\$4) same phase\$5shift\$4) and ((irradiat\$4 or illuminat\$4 or expos\$4) same (photoresist or resist or photosensitive))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
10	4	S9 NOT S6	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
11	18	((phase near9 shift\$4 near9 mask) same chrome\$2less) and (pluralit\$4 same (transparen\$3 or transmiss\$6) same (feature or pattern)) and ((pluralit\$8 or multi\$4 or second) same phase\$8shift\$4) and ((irradiat\$4 or illuminat\$4 or expos\$4) same (photoresist or resist or photosensitive))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
12	33	430/5.ccls. and ((phase near9 shift\$4 near9 mask) same chrome\$2less) and (pluralit\$4 same (transparen\$3 or transmiss\$6) same (feature or pattern)) and ((irradiat\$4 or illuminat\$4 or expos\$4) same (photoresist or resist or photosensitive))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
13	31	430/5.ccls. and ((phase near9 shift\$4 near9 mask) same chrome\$2less) and (pluralit\$4 same (transparen\$3 or transmiss\$6) same (feature or pattern)) and ((irradiat\$4 or illuminat\$4 or expos\$4) same (photoresist or resist or photosensitive)) and (IC or circuit\$6 or logic or memory)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
14	34	"430"/\$.ccls. and ((phase near9 shift\$4 near9 mask) same chrome\$2less) and (pluralit\$4 same (transparen\$3 or transmiss\$6) same (feature or pattern)) and ((irradiat\$4 or illuminat\$4 or expos\$4) same (photoresist or resist or photosensitive)) and (IC or circuit\$6 or logic or memory)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB